# Fully Chlorinated N-Silyl Amides of Titanium and Tungsten – Crystal Structure of Cl<sub>3</sub>SiNW(Cl<sub>3</sub>)N(SiCl<sub>3</sub>)<sub>2</sub>

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The reaction of hexachlorodisilazanyllithium  $(Cl_3Si)_2NLi$  (1), with TiCl<sub>4</sub> leads selectively to the novel fully chlorinated amides  $(Cl_3Si)_2NTiCl_3$  (2) or  $[(Cl_3Si)_2N]_2TiCl_2$  (3), respectively, depending on the molar ratio of the starting materials. The analogous reaction of 1 with WCl<sub>6</sub> yielded the amide imide  $Cl_3SiN \equiv W(Cl_3)N(SiCl_3)_2$  (5) by elimination of SiCl<sub>4</sub>. The relative amounts of the starting materials had no effect

Fully chlorinated *N*-silylamido or -imido compounds are promising candidates for molecular preorganization leading to novel polymer, and highly crosslinked, silicon-nitrogen networks. For example SiPN<sub>3</sub><sup>[1]</sup> has been synthesized via the molecular precursor Cl<sub>3</sub>Si $-N=PCl_3$ , which already contains the required structural element of two vertex-sharing tetrahedra centered by, respectively, a phosphorus or a silicon atom, which are connected through a common nitrogen atom. Ammonolysis of this precursor, followed by thermal condensation, preserves this structural element and directly yields the highly crosslinked crystalline ceramic compound SiPN<sub>3</sub>, which contains a network structure of corner-sharing SiN<sub>4</sub> and PN<sub>4</sub> tetrahedra<sup>[1]</sup>. A similar approach has been used for the synthesis of the non-crystalline ceramic Si<sub>3</sub>B<sub>3</sub>N<sub>7</sub><sup>[2]</sup>.

In the context of a systematic investigation of nitrido bridges between main-group elements and transition metals, we are now targeting molecular precursor compounds which might be valuable for the synthesis of ternary nitrides, or nanocomposites, in the system Ti-Si-N and W-Si-N. As in the synthesis of SiPN<sub>3</sub>, fully chlorinated *N*-silylamido or -imido compounds of Ti and W seem to be appropriate candidates for this synthetic approach.

Several *N*-trimethylsilyl amides or imides with a large number of transition metals and main-group elements exist. Their synthesis by the reactions of metal halides with hexamethyldisilazane or with hexamethyldisilazanyllithium have been extensively studied in the literature<sup>[3-8]</sup>. In contrast there are only a few compounds reported with nitrogenbearing trichlorosilyl groups instead of trimethylsilyl groups<sup>[9-11]</sup>, and Zn is the only transition metal reported so far<sup>[11]</sup> in these systems.

Wannaget et al. have already investigated the preparation and the reactivity of hexachlorodisilazane and showed that N-lithiation is readily achieved by treatment with nBuLi on the formation of **5**. <sup>14/15</sup>N- and <sup>29</sup>Si-NMR data on the starting materials and products show significantly different effects, when compared with those of analogous *N*-trimethylsilyl derivatives, due to the lower energy of the electrons in the N–Si and N–M  $\sigma$  bonds. The crystal structure of **5** (triclinic, space group  $P\bar{1}$ ) was determined by X-ray structure analysis.

in pentane to give hexachlorodisilazanyllithium (1; see Equation 1)<sup>[9]</sup>. Recently, Burgdorf et al. described an improved synthesis of chlorodisilazanes starting from  $CaCl_2(NH_3)_8^{[12]}$  (see Equation 2). Reactions of 1 were carried out with boron and silicon halides and the possibility of substitution reactions was shown in principle<sup>[10]</sup>.



Here we report on the synthesis and characterization of fully chlorinated *N*-silylamides obtained by the reaction of 1 with  $TiCl_4$  and  $WCl_6$ .

### **Results and Discussion**

The reactions of 1 with TiCl<sub>4</sub> are summarized in Scheme 1. The mono-substituted product 2 is obtained in high yield by the reaction of 1 with TiCl<sub>4</sub> in a molar ratio of 1:1 (Scheme 1a). It is a yellowish solid which gives bright yellow solutions in organic solvents. The treatment of 1 with TiCl<sub>4</sub> in a molar ratio of 2:1 (Scheme 1b) gives the corresponding diamide 3. On heating, 3 decomposes to 2 and the well-characterized 4-membered ring  $6^{[9b,13]}$  (Scheme 1c).

# FULL PAPER

Scheme 1



The reaction of 1 with WCl<sub>6</sub> (Scheme 2) leads directly to the amide imide 5 which can be recrystallized from pentane to give yellow crystals (vide infra). Solutions of 5 in aromatic solvents exhibit a dark brown color. The formation of 5 can be explained by the elimination of SiCl<sub>4</sub> from the proposed intermediate 4, resulting in a W=N multiple bond (Scheme 2b). This type of reaction is well known for the analogous *N*-trimethylsilyl derivatives, e.g. with tantalum as the central atom<sup>[4a]</sup>. The relative amounts of the starting materials 1 and WCl<sub>6</sub> may be varied across a wide range without any effect on the formation of 5. Obviously, a monosubstitution product analogous to 2 is much more reactive towards 1 than WCl<sub>6</sub> itself.

Scheme 2



#### Crystal Structure of 5<sup>[14]</sup>

Details of the X-ray structure analysis of **5** are summarized in Table 1. The tungsten amide imide  $Cl_3SiN \equiv$  $W(Cl_3)N(SiCl_3)_2$  is monomeric. There are no significantly short intermolecular atomic distances. The coordination sphere of the central atom of **5** is best described to be of pseudo-square-pyramidal geometry, with the imido group at the apex. The SiCl<sub>3</sub> groups [Cl<sub>3</sub>Si(3)] and [Cl<sub>3</sub>Si(1)] show rotational disorder. The imido group is nearly linear [angle  $W \equiv N - Si \ 165.4(6)^\circ$ ] and the imido nitrogen atom can be viewed as sp-hybridized. The coordination of the amido nitrogen atom is trigonal planar. The two bonds between W and N differ by nearly 30 pm [W \equiv N \ 171.8(9), W-N 200.7(8) pm] which is significantly larger than the value found for the comparable dimeric tantalum compound  $[Me_3SiN \equiv Ta(Br_2)N(SiMe_3)_2]_2^{[4a]}$ . The bond lengths W–N are in the same range as those found for other tungsten amides and imides<sup>[15–17]</sup>. In contrast to the tantalum derivative  $[Me_3SiN \equiv Ta(Br_2)N(SiMe_3)_2]_2$ , the hybridization of the nitrogen atoms in **5** has no effect on the N–Si bond lengths (average value 171.5 pm) which correspond to those of a normal Si–N single bond<sup>[13]</sup> which also holds for the W–Cl bond lengths<sup>[18]</sup>. The bond lengths Si–Cl of the Si(2)Cl<sub>3</sub> group are as expected<sup>[13]</sup> (bond lengths in the rotationally disordered groups were fixed).

Figure 1. Molecular structure of 5<sup>[a]</sup>



<sup>[n]</sup> Selected bond lengths [pm] and angles [°]: W Cl1 229.8(3), W-Cl2 231.4(3), W-Cl3 230.5(3), N1-Si1 171.1(9), N2-Si2 171.4(8), N2-Si3 172.5(10); N1-W-N2 104.0(4), N1-W-Cl1 102.5(3), N2-W-Cl1 153.5(3), N1-W-Cl2 98.5(3), Cl2-W-Cl3 162.1(1), W-N1-Si1 165.4(6).

Table 1. Crystallographic data of 5

Empirical formula	Cl <sub>12</sub> N <sub>2</sub> Si <sub>3</sub> W
Crystal system, space group	triclinic, P 1
Unit-cell dimensions [pm] [°]	a = 879.8(2)
	b = 888.5(2)
	c = 1318.4(2)
	$\alpha = 99.14(2)$
	β = 98.10(2)
	γ = 100.55(2)
Unit-cell volume V [10 <sup>6</sup> pm <sup>3</sup> ]	985.0(3)
Z	2
Density (calcd.) [g/cm <sup>3</sup> ]	2.433
Diffractometer, radiation	Siemens P4, Mo- $K_{\alpha}$ ,
	λ = 71.073 pm
Temperature [K]	296
20 range [°]	2.0–55.0
Reflections collected	5391, ω scan
Independent reflections	4509 (R <sub>int</sub> = 0.0423)
Observed reflections	4181 with <i>F</i> ₀ ≥ 2.0 σ( <i>F</i> ₀)
Absorption correction	semi-empirical (y scans)
Min./max. transmission factors	0.0282/0.0575
Solution	direct methods
Number of parameters refined	162
Program	Siemens SHELXTL PLUS
	(VMS)
$R/wR[w^{-1} = \sigma^2(F_o)]$	0.0583/0.0571

Crystalline 5 shows a reversible phase transition between room temperature and -100 °C, associated with an enlargement of the unit cell without destruction of the single crystal.

#### NMR Spectroscopic Results

The measured NMR data of hexachlorodisilazane and of the compounds 1-6 are listed in Tables 2 and 3. All NMR data of the compounds 2 and 3 are consistent with the proposed structures. Because of the absence of any protons which could be used for polarization transfer only direct <sup>29</sup>Si-NMR measurements were possible. The <sup>29</sup>Si nuclei of the transition-metal derivatives are shielded by 4-8 ppm when compared with hexachlorodisilazane; this is caused by the replacement of the proton by a transition-metal halide group. In contrast, the <sup>29</sup>Si nuclei of (Me<sub>3</sub>Si)<sub>2</sub>N-TiCl<sub>3</sub>, the methyl analogue of 2, are deshielded with respect to hexamethyldisilazane<sup>[19]</sup>. The replacement of a second chlorine atom at the titanium center against a bis(trichlorosilyl)amido group leads to further <sup>29</sup>Si shielding by 1.8 ppm. The trichlorosilyl groups at the imido nitrogen atoms of 5 give signals with a high shielding at  $\delta = -59.8$ . This significantly high shielding of the ring Si nuclei in 6 to a value of  $\delta = -39.8$  is typical of 4-membered rings, and is probably a result of the short transannular Si-Si distance of 246.3 pm<sup>[13]</sup> which is comparable to a covalent Si-Si single bond length of 234 pm<sup>[20]</sup>.

Table 2. <sup>14</sup>N- and <sup>29</sup>Si-NMR data<sup>[a]</sup> of hexachlorodisilazane, compounds 1-3, and 6

Compound	Hexachloro- disilazane <sup>[b]</sup>	1	2	3	6
δ <sup>14</sup> N (ν <sub>1/2</sub> ) δ <sup>29</sup> Si	313 (430) 25.5	-283 (250) -43.5	–117 (160) –29.6	–140 (510) –31.4	283 (220) 30.2 (SiCl <sub>3</sub> ) 39.8 (SiCl <sub>2</sub> )

 ${}^{[a]}$  C<sub>6</sub>D<sub>6</sub>, 25 °C. -  ${}^{[b]}$   $\delta^1 H =$  2.82;  ${}^1J[{}^{15}N, {}^1H] =$  71.9 Hz;  ${}^1J[{}^{29}Si, {}^{15}N] =$  28.8 Hz.

$Cl_{3}Si - N \equiv W \begin{pmatrix} SiCl_{3} \\ I \\ Cl_{3}Si - N \equiv W \\ Cl \\ Cl \\ Cl \\ Cl \\ SiCl_{3} \\ SiCl_{3} \\ Cl \\ SiCl_{3} \\ SiCl_{3} \\ Cl \\ SiCl_{3} \\ SiC$						
δ <sup>14</sup> N (v <sub>1/2</sub> ) (N-I)	$\delta^{14}N(v_{1/2})$ (N-II)	δ <sup>29</sup> Si (Si-I)	δ <sup>29</sup> Si (Si-II)			
93 (110)	-167 (310)	-59.8	-33.1			

<sup>[a]</sup> C<sub>6</sub>D<sub>6</sub>, 25°C.

The most instructive information on the product distribution, and on the progress of the reactions, is obtained by <sup>14</sup>N-NMR spectroscopy. Previously, only a few <sup>14/15</sup>N chemicals shifts of transition-metal amides and imides were measured<sup>[17]</sup>, most of them by <sup>15</sup>N-NMR spectroscopy of samples enriched with <sup>15</sup>N<sup>[17,21]</sup>. Our investigations on <sup>14</sup>N-NMR spectroscopy show that the resonances of transition-metal amides and imides are surprisingly easy to observe (see Figure 2).





The substitution of the proton of hexachlorodisilazane against lithium in 1 leads to a <sup>14</sup>N deshielding of 30 ppm and to a sharpening of the <sup>14</sup>N-NMR signal. The  $\delta^{14}$ N values of the compounds 2 ( $\delta^{14}$ N = -117) and 3 ( $\delta^{14}$ N = -140) can be explained by the lower acidity of the TiCl<sub>2</sub> group when compared with that of the TiCl<sub>3</sub> group. In a mixture, the increase of the line width of the <sup>14</sup>N-NMR signal due to the higher molecular weight of 3 (Figure 2) is also indicative. The low <sup>14</sup>N shielding, together with a sharp <sup>14</sup>N-resonance signal for the imido-nitrogen atom of 5, is typical of sp-hybridized <sup>14</sup>N atoms<sup>[17,21,22]</sup>.

The marked <sup>14</sup>N deshielding in metal amides or imides, if the metal is an early transition element in a high oxidation state, may be explained by the contribution to the paramagnetic shielding term  $\sigma_p$  of B<sub>0</sub>-induced mixing of ground and electronic excited states. This concerns in particular the electrons in the M–N  $\sigma$  bond, the nitrogen lone pair of electrons, and the presence of unoccupied metal dorbitals. The comparison between  $\delta^{14}N$  of 2 ( $\delta^{14}N = -117$ ) and  $(Me_3Si)_2NTiCl_3$  ( $\delta^{14}N = +30^{[19]}$ ) indicates the influence of the electronegative chloro substituents. The energy of electrons in the N–Si and also in the M–N  $\sigma$  bonds, as well as that of the lone pairs of electrons, is lower in 2 than in  $(Me_3Si)_2NTiCl_3$ . Therefore, the mean  $\Delta E$  is larger in 2 and paramagnetic contributions become smaller<sup>[23]</sup> i.e. <sup>14</sup>Nnuclear shielding increases. The same arguments explain the high shielding of the <sup>29</sup>Si nuclei. However, in comparison with amines, the effect of the neighboring metal center still dominates the <sup>14</sup>N deshielding but not the <sup>29</sup>Si shielding in 2, 3, and 5.

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### **Experimental Section**

All preparative work and handling of the samples was carried out under pure  $N_2$  using dry glassware and dry solvents.

### FULL PAPER

CaCl<sub>2</sub>(NH<sub>3</sub>)<sub>8</sub><sup>[12]</sup> and hexachlorodisilazanyllithium (1)<sup>[9b]</sup> were prepared as described. The preparation of hexachlorodisilazane is analogous to literature procedures<sup>[12]</sup>. SiCl<sub>4</sub>, TiCl<sub>4</sub>, WCl<sub>6</sub>, and nBuLi in hexane (1.6 M) were commercial products and used without further purification. - IR spectra: Bruker IFS 66v/; KBr pellets. - NMR spectra: Bruker ARX 250 (<sup>1</sup>H, <sup>14</sup>N, <sup>15</sup>N, <sup>29</sup>Si); chemical shifts are given with respect to Me<sub>4</sub>Si [ $\delta^1$ H (C<sub>6</sub>D<sub>6</sub>) = 7.15;  $\delta^{29}$ Si:  $\Xi(^{29}\text{Si}) = 19.867184 \text{ MHz}$  and neat MeNO<sub>2</sub> [ $\delta^{14}$ N:  $\Xi(^{14}$ N) = 7.223656 MHz;  $\delta^{15}$ N:  $\Xi(^{15}$ N) = 10.136767 MHz].

(Cl<sub>3</sub>Si)<sub>2</sub>NH: To a cooled (-78°C) solution of 400 g of SiCl<sub>4</sub> (2.4 mol) in 500 ml of pentane, 40 g of  $CaCl_2(NH_3)_8$  (0.16 mol  $\approx 1.28$ mol of NH<sub>3</sub>) was added in one portion. Then the mixture was stirred at room temp. for 8 d. After that, the reaction mixture was filtered, and pentane and SiCl<sub>4</sub> were removed from the filtrate by distillation. Distillation of the residue at reduced pressure gave 60 g (18%) of hexachlorodisilazane as a colorless, extremely moisturesensitive liquid (b.p. 81°C/40 Torr).

 $(Cl_3Si)_2N - TiCl_3$  (2) and  $[(Cl_3Si)_2N]_2TiCl_2$  (3): To a solution of 0.7 g of 1 (2.4 mmol) in 20 ml of CH<sub>2</sub>Cl<sub>2</sub> at -78°C, 0.5 g (2.4 mmol) or 0.25 g (1.2 mmol) of TiCl<sub>4</sub>, respectively, were added in one portion. After the mixture was warmed to room temp., it was stirred for 4 h. Then the mixture was filtered. Removal of the solvent from the filtrate gave 1.0 g of 2 (95%; m.p. 190°C) or 0.8 g of 3 (97%; m.p. 140°C under decomposition), as yellowish solids. -3: IR:  $\tilde{v}$  [cm<sup>-1</sup>] = 1405, 985, 815, 746, several vibrations between 400 and 630.

 $Cl_3SiN \equiv W(Cl_3)N(SiCl_3)_2$  (5): A solution of 0.7 g of 1 (2.4 mmol) in 10 ml of CH<sub>2</sub>Cl<sub>2</sub> was added carefully to a stirred solution of 0.5 g of WCl<sub>6</sub> (1.3 mmol) in 20 ml of CH<sub>2</sub>Cl<sub>2</sub> at  $-78^{\circ}$ C. The mixture was allowed to warm up. At a temperature of 0°C the color changed from dark brown to yellow and LiCl began to precipitate. After stirring for 1 h at room temp., the reaction mixture was filtered. Removal of the solvent in vacuo from the filtrate gave an orange oil. Recrystallization from pentane gave 0.5 g of 5 (58%) as yellow platelets (m.p. 115°C). – IR:  $\tilde{v}$  [cm<sup>-1</sup>] = 1403, 1178 [vW≡N)], 1083, 964, 772, 624, several vibrations between 400 and 600.

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